

Section 6. Low / High Temperature Manipulators



Multi-axis Cryo-manipulator
6-1/2



Variable Temperature Insert (VTI)
6-4



Multi- axis High Temperature Manipulator
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Modules & accessories
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Multi-axis Helium-free Manipulator



Highlights

- › Cooled by GM cryocooler
- › Low cost of ownership
- › Multiple Axis: Up to 6
- › Temperature range: < 6K-325K
- › RT to 6K: < 4 hours

» Options

✓ Sample parking stage

✓ Secondary Low Temperature Stage

✓ High Temperature (E-beam) Stage

✓ Sample Floating Module

✓ YAG Stage

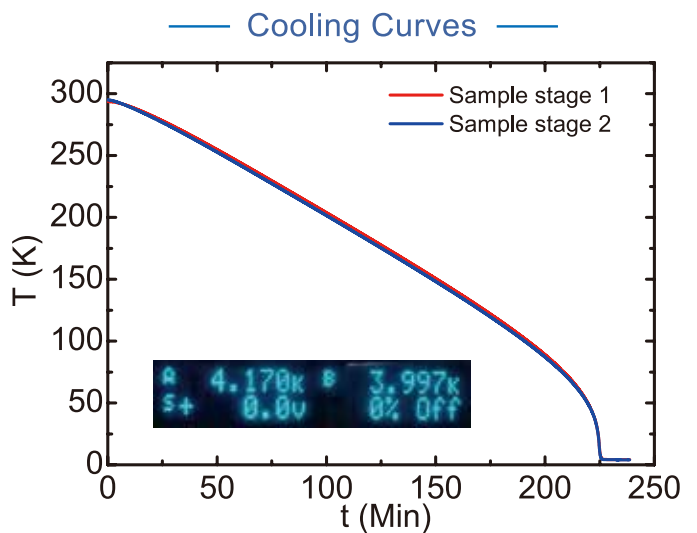
✓ Auto Mapping Module

✓ Low Temperature Cleavage Module

✓ Four-probe Transport Module

» Mechanical Specifications

Polar rotation	360° (-180°, +180°)
Tilt rotation	60° (-15°, +45°)
Azimuthal rotation	240° (-120°, +120°)
X / Y stroke	25mm(max 50mm)
Z stroke	Up to 650mm



Multi-axis Low Helium Consumption Manipulator



Highlights

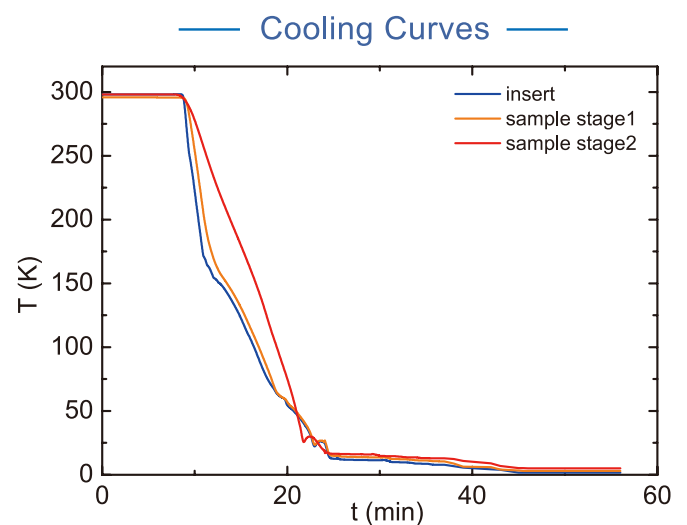
- › Cooled by liquid helium
- › Multiple Axis: Up to 6
- › Temperature range: 3K-400K
- › RT to 10K, < 15 min
- › Liquid nitrogen compatible: < 65K Operation (with pump)

» Options

- | | |
|-----------------------------------|-----------------------------------|
| ✓ Sample parking stage | ✓ YAG Stage |
| ✓ Secondary Low Temperature Stage | ✓ Auto Mapping Module |
| ✓ High Temperature (E-beam) Stage | ✓ Low Temperature Cleavage Module |
| ✓ Sample Floating Module | ✓ Four-probe Transport Module |

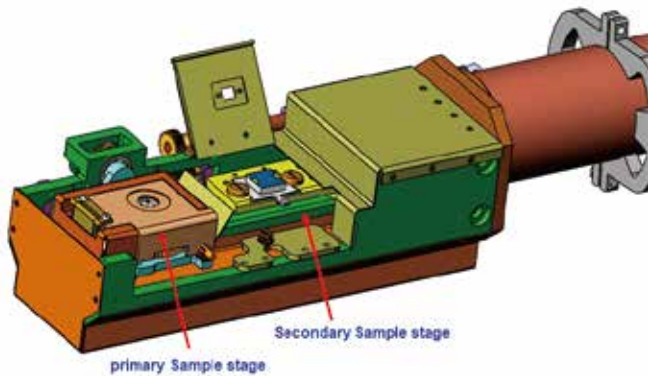
» Mechanical Specifications

Polar rotation	360° (-180°, +180°)
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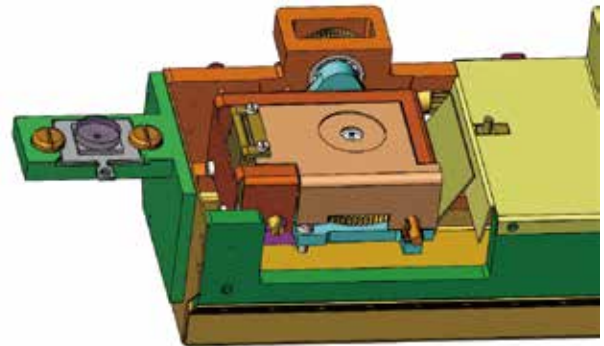
Options

» Secondary Low Temperature Sample Stage



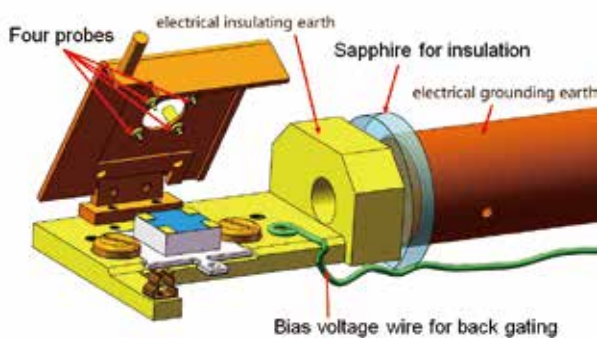
- ✔ Compatible with flag type sample holder
- ✔ Compatible with LEED measurement
- ✔ Silicon diode sensor
- ✔ Temperature range: 4.5K-400K
- ✔ Temperature controller replaced by Lakeshore 336

» Photocurrent Measurement Module



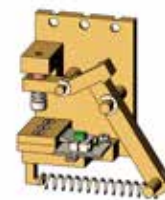
- ✔ Including Sample Floating Module
- ✔ YAG crystal on sample holder to monitor the light spot
- ✔ Aluminum foil on sample holder to measure the light intensity
- ✔ Kapton insulated wire for photocurrent measurement

» Four-probe Transport Measurement Module



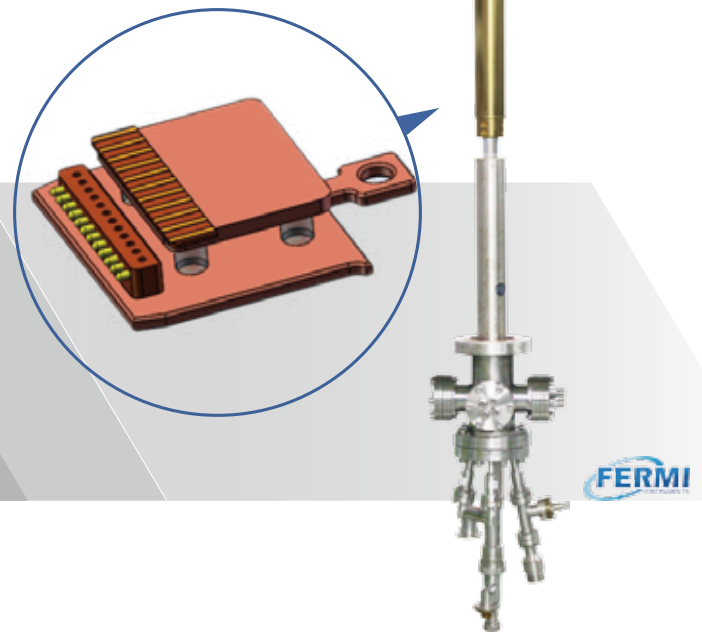
- ✔ Back gating (or sample floating) module
- ✔ Four probes for sample bias or transport measurements
- ✔ Insulation breakdown voltage: 100 V DC
- ✔ Min. bias Current: 0.1nA

» Low Temperature Cleavage Module



- ✔ Mounting at the bottom of shielding
- ✔ Compatible with flag type sample holder but with special sample's fasteners
- ✔ Suitable for many times cleaving before opening the UHV system
- ✔ For surface preparation of hard ionic crystals (e.g. MgO) with high precision

Variable Temperature Insert (VTI)



Variable Temperature Insert (VTI) is a continuous flow cryostat that can provide a temperature range from 1.5K to 400K. Various sample stages can be mounted onto the cold head in UHV environment.

Highlights

- › Initial Cooling time (from RT to 10K): < 15min
- › Temperature range: 67-400 K with LN2
- › Temperature range: 1.5-400K with LHe
- › Lowest temperature achieved: 1.5 K(with pump)
- › LHe consumption: $\leq 0.3\text{L/h}$ above 10K
- › LN2 consumption: 0.5L/h LN2 at 100K
- › Bakeable: Up to 120°C

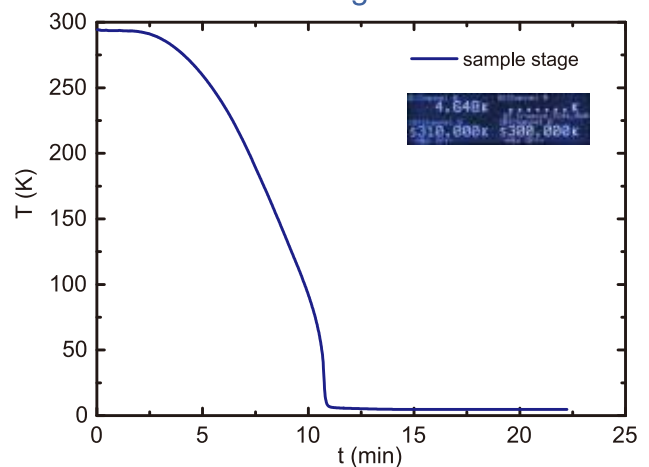
Applications

- ✔ Surface measurement
- ✔ Optical science
- ✔ Transport measurement

Configuration

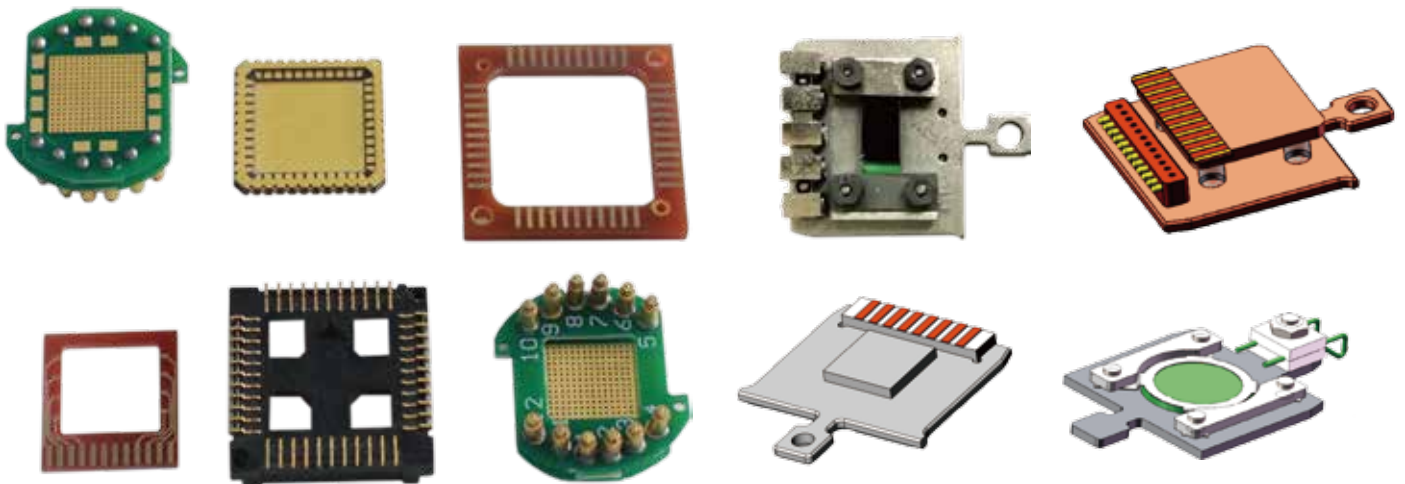
- ✔ CF100,63,35 Mounting flange available
- ✔ 1-5 spare CF16 flanges available
- ✔ Two temperature sensors
- ✔ One control heater
- ✔ Optional radiation shield
- ✔ Optional UHV electrical feedthrough
- ✔ Optional electrical insulation
- ✔ Optional temperature controller
- ✔ Optional LN2 or LHe transfer line

Cooling Curves

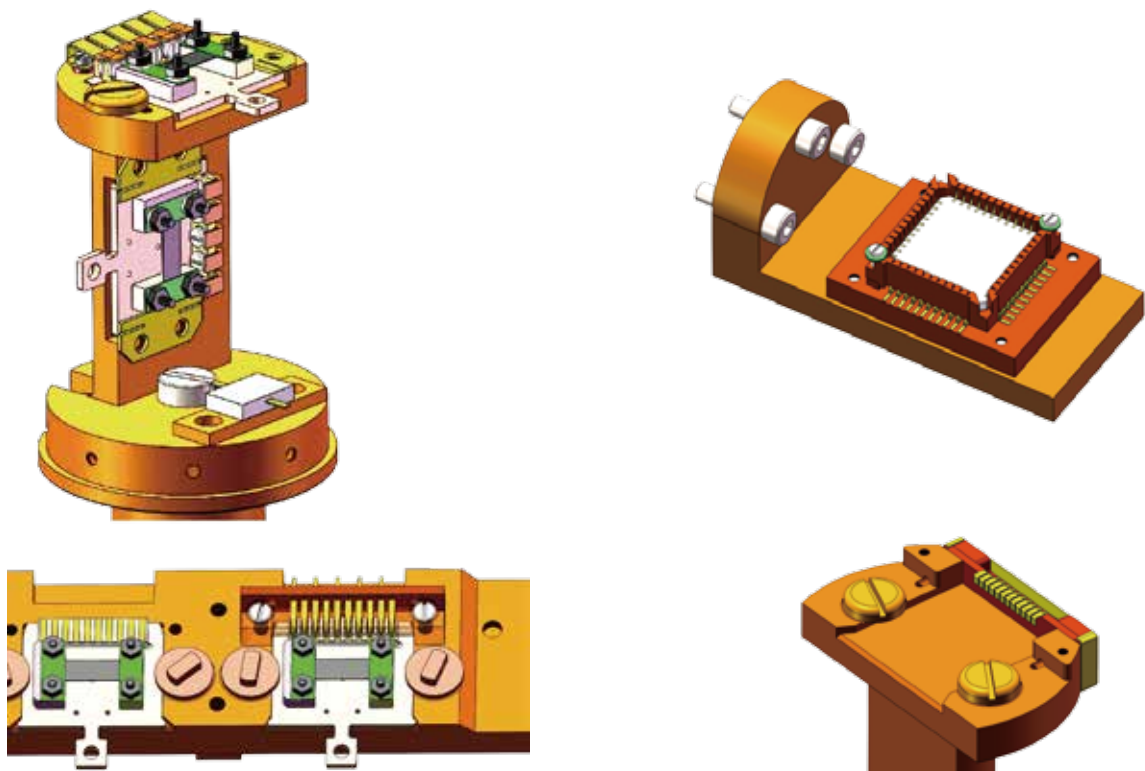


Options

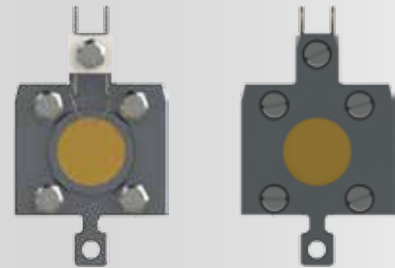
sample holders



Sample stages



TPD Manipulator



Temperature-Programmed Desorption (TPD) is used to study thermodynamics and kinetics of desorption from solid surfaces while its temperature is changed in a controlled manner.

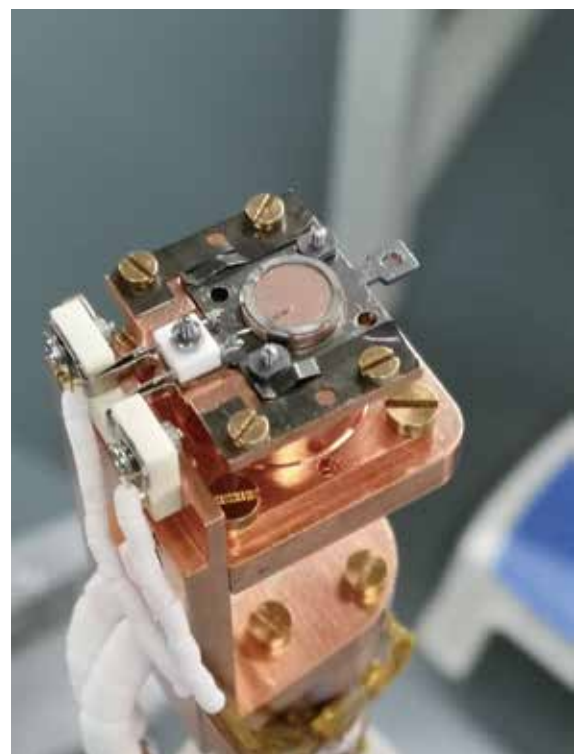
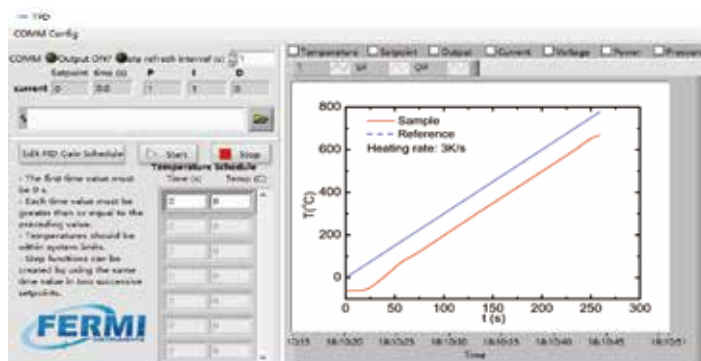
Highlights

- › Intergrated temperature sensor and filament
- › Easy sample/ filament changing
- › Fully Temperature control and data logging
- › Restricted heating area
- › Quick sample cooling
- › Low background degasing
- › Up to 4-axis movement

» Applications

- ✓ Catalysis Analysis
- ✓ Thermal Analysis
- ✓ Thin Films Engineering
- ✓ Surface Engineering
- ✓ Residual Gas Analysis

» TPD Stage



» Standard Technical Data

Max.sample lateral size	10mm
Max.sample height	2mm
Sample heating	up to 1000K
Sample cooling	down to 90K(LN2)
Heating rate	0.1-3K/s
Cooling rate	10min(1000K to RT)

Optical cryostat



Optical cryostat for use in microscopy, spectroscopy, wafer probing, IC testing and more.

Highlights

- › The windows and sample holders can be easily changed
- › Easy to use: A range of window materials are available
- › Configured for reflectance and transmission measurements
- › Lowest temperature achieved: 1.5 K(with pump)
- › Operates in any orientation
- › Compact, lightweight and portable
- › Short working distance

» Specifications

- ✔ liquid helium or nitrogen compatible
- ✔ Low liquid helium consumption, < 0.5 L/h
- ✔ Temperature range : < 4K to 325K
- ✔ Fast Cooling: RT to 4.2 K around 10 minutes
- ✔ 8-pin electrical feedthrough for temperature control
- ✔ 8- pin electrical feedthrough for transport
- ✔ Measurement-ready, via 8-pin electrical wiring to the sample

» Options

- ✔ Optional superconducting magnet field
- ✔ Optional low-loss flexible transfer line
- ✔ Optional Lakeshore temperature controller

E-Beam Sample Heating Stage



The modular design guarantees this E-beam Sample Heating Stage is easy mounting and changing. The sample plate can be heated radiatively or by electron bombardment.

Highlights

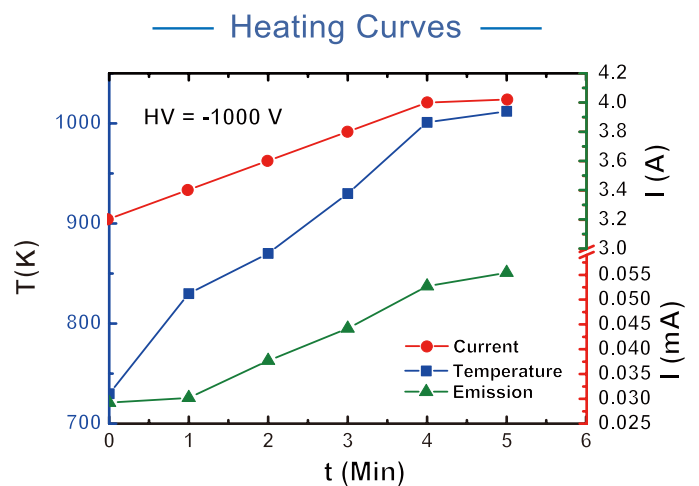
- › Compatible with all our cryomaipulator
- › Tungsten- Thorium Oxide heating wire
- › Easy sample/ filament changing
- › Efficient/ Quick sample heating
- › High voltage applied to the filament
- › Flag type sample holder
- › Up to 4-axis movement
- › Compatible with UHV environment
- › Optional pyrometer sensor

» Working State

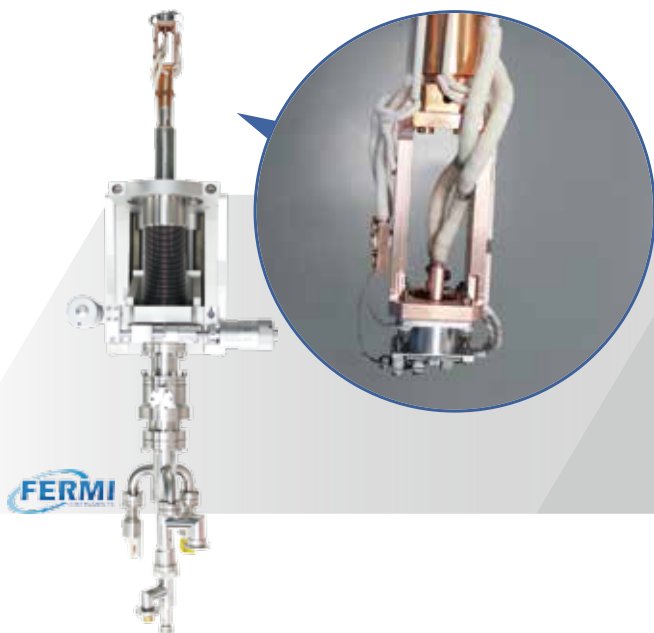


» Technical Data

High voltage	-1000V
Heat power	up to 80W
Radiation heating	up to 500 °C
E-beam heating	up to 1000 °C
Thermocouple	K/E type
Heating rate	20sec to 1000 °C



4 Axes High/ low Temperature Manipulator



Highlights

Coaxial design LN2 cooling head

- › Excellent thermal isolation
- › Fast cooling

Side sealing DPRF

- › No pumping needed for 10^{-8} mbar
- › Single port pumping for 10^{-10} mbar
- › Self locking mechanism for R1

Guide tube

- › High strength supporting tube for smooth sample transfer

2000°C heating stage

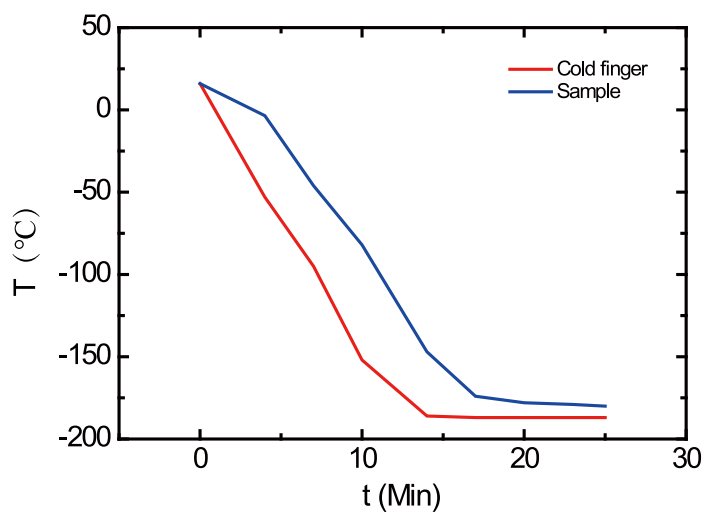
- › Optional direct heating module

» Standard Technical Data

Temperature regulation	Control Range
Radiative heating	RT-1200°C
E-beam heating	RT-2000°C
Direct heating	RT-1400°C
LN2 Cooling	-150°C-RT

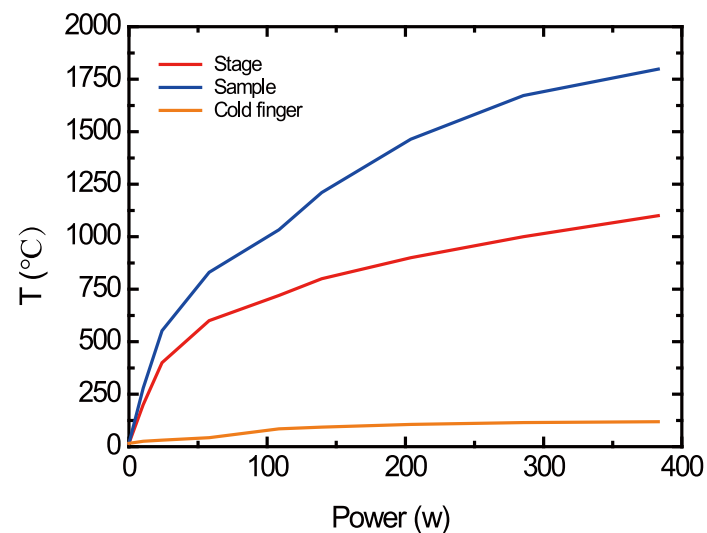
Polar rotation	360°
X and Y movements	±9mm
Z movements	Up to 300mm

Cooling curves

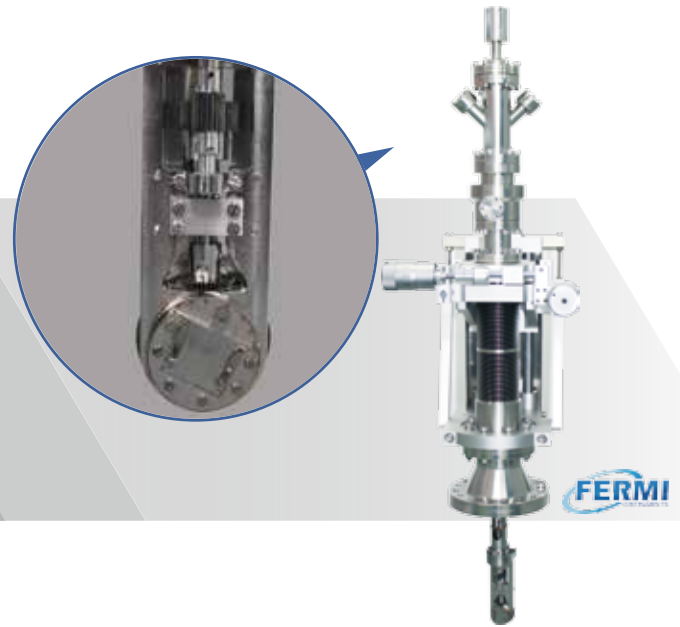


*20 min from RT to 80K

Heating Curves



5 Axes High Temperature Manipulator



Highlights

High precision R3 manipulation

- 4:1 gear ratio, high precision: $\Delta \sim 0.03^\circ$
- Smooth rotation

Side sealing DPRF R1

- Decoupling R1 and R3 rotation

Guide tube

- High strength supporting tube for smooth sample transfer

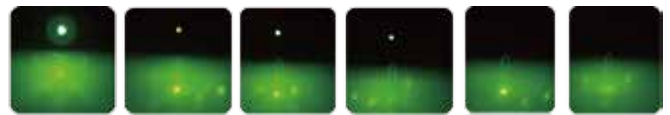
High temperature R3 rotation stage

- Excellent thermal isolation and minimum heat transfer
- 360° Continuous rotor design
- E-beam compatible design

Technical Data

Temperature regulation	Control Range
Radiative heating	RT-1000°C
Azimuthal rotation	360°
X and Y movements	±9mm
Z movements	Up to 300mm

➤ Excellent for RHEED

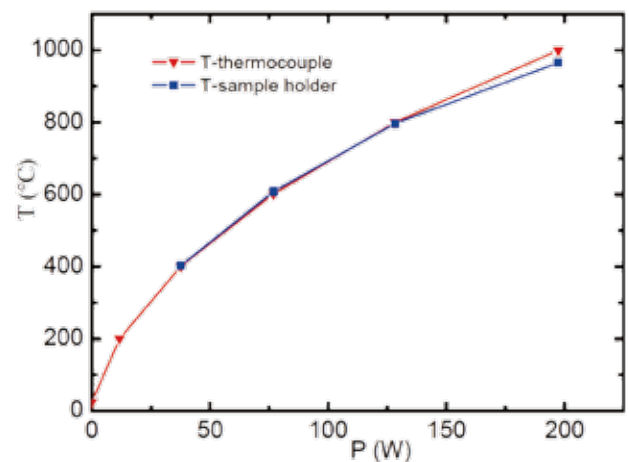


➤ High Temperature Rotation



*Si₃N₄ bearing support for rotation
at temperature up to 1000°C

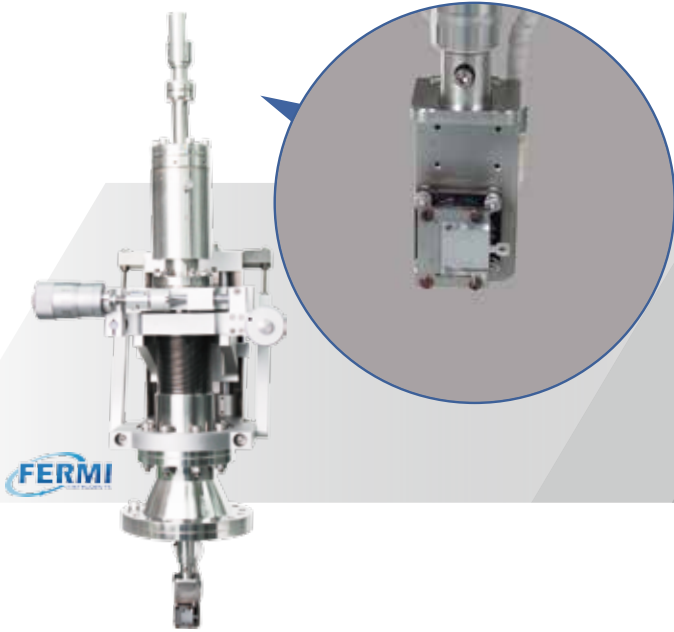
— Heating Curves —



*Heat up to 1000°C

*Reliable reference T_c measurement
($\Delta < 50^\circ\text{C}$ from T_s)

4 Axes High Temperature Manipulator



FERMI

Highlights

Magnetic coupled Rotary feedthrough

- ▶ $\pm 179^\circ$ rotation

Supporting tube

- ▶ High strength supporting tube for smooth sample transfer
- ▶ Wiring inside the tube, no interference in manipulation

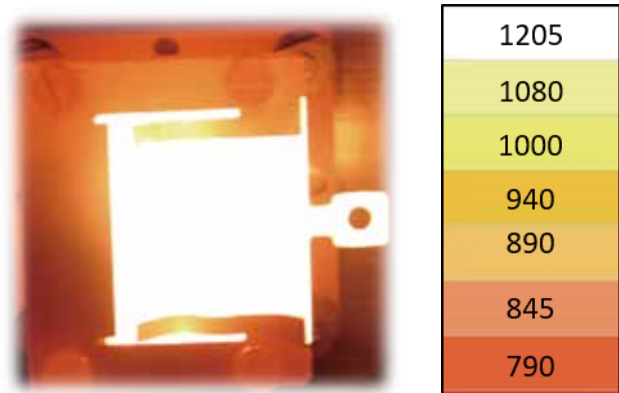
Heating stage

- ▶ Same design in all 4 axes STD. stage
- ▶ Molybdenum stage, Low degassing
- ▶ 1200°C for radiative heating
- ▶ 2000°C for e-beam heating
- ▶ Optional direct heating module

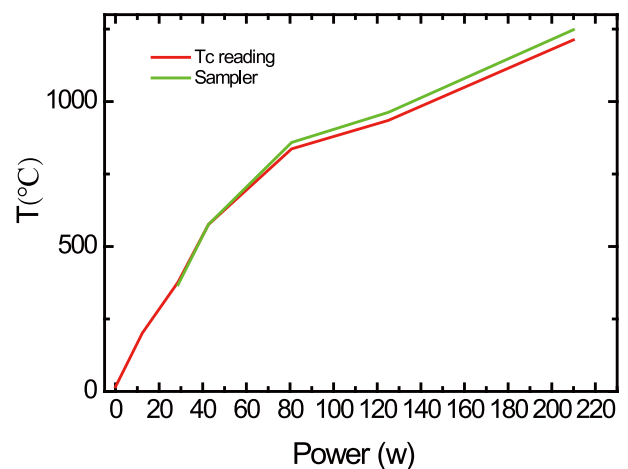
Technical Data

Temperature regulation	Control Range
Radiative heating	RT-1200°C
E-beam heating	RT-2000°C
Direct heating	RT-1400°C
Polar rotation	$\pm 179^\circ$
X and Y movements	$\pm 9\text{mm}$
Z movements	Up to 300mm

Excellent temperature uniformity



Heating Curves



*Reliable reference T_c measurement
($\Delta < 50^\circ\text{C}$ from T_s)